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HIPIMS Deposition of TiAlN Films on Inner Wall of Micro-Dies and Its Applicability in Micro-Sheet Metal Forming

Tetsuhide Shimizu, Hidetoshi Komiya, Tomotaro Watanabe, Yoshikazu Teranishi, Hiroshi Nagasaka, Kazuo Morikawa, Ming Yang

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Tetsuhide SHIMIZU¹*,

Hidetoshi KOMIYA²,

Tomotaro WATANABE²,

Yoshikazu TERANISHI²,

Hiroshi NAGASAKA²,

Kazuo MORIKAWA²,

Ming YANG¹

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